

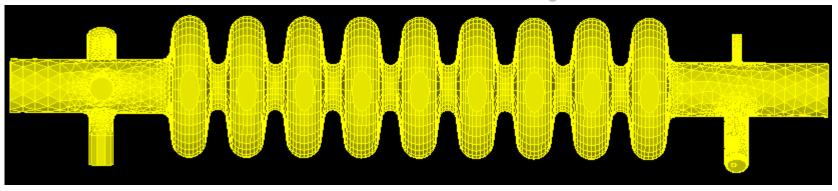
Multipacting Phenomena simulations for the Crab cavity

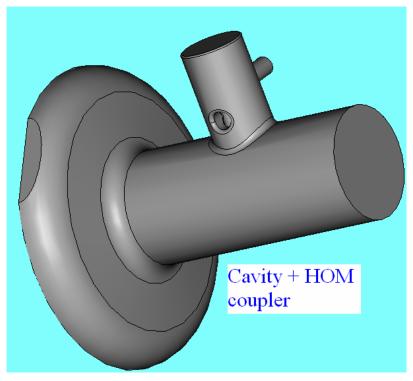
Valentin Ivanov FNAL 8 March 2007

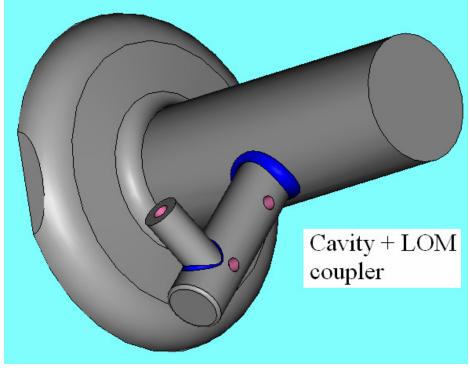
Outline

- 9-cell Crab cavity with couplers
- MP study in 1-post HOM coupler
- MP study in 2-post HOM coupler
- MP in LOM coupler (FNAL design)
- Acknowledgments
- Summary

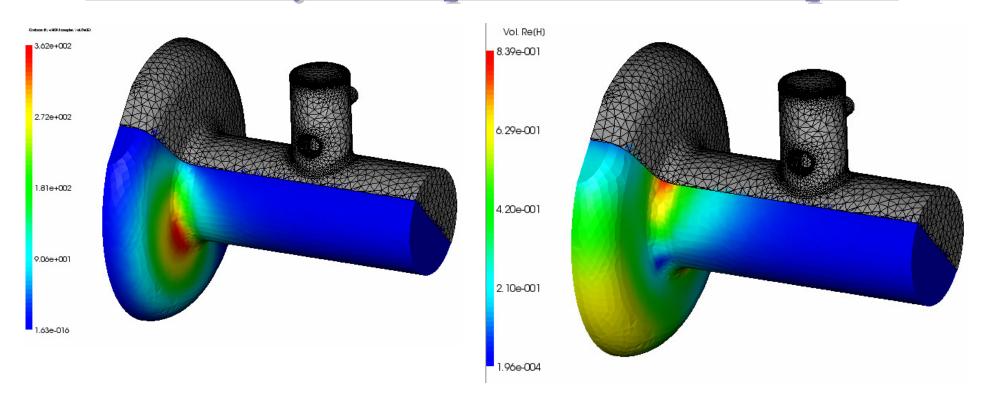
9-cell Cavity







MP Study in 1-post HOM Coupler

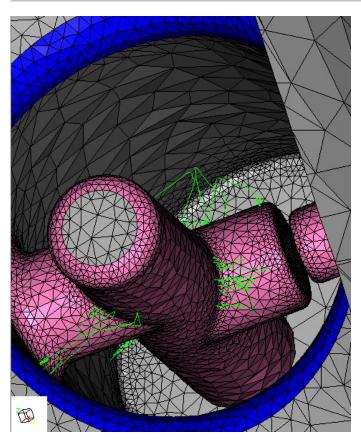


Electric field

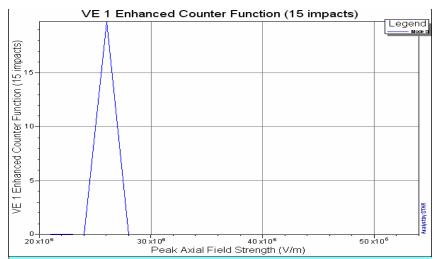
Magnetic field

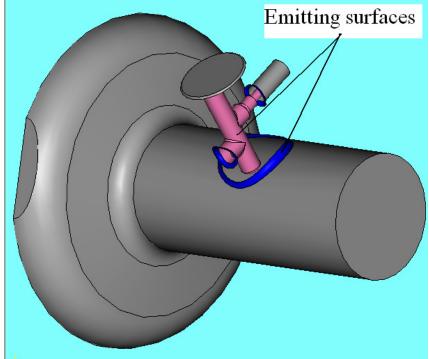
Tetrahedral mesh ~33,000 nodes; 200,000 DOF.

MP Phenomena in HOM Coupler

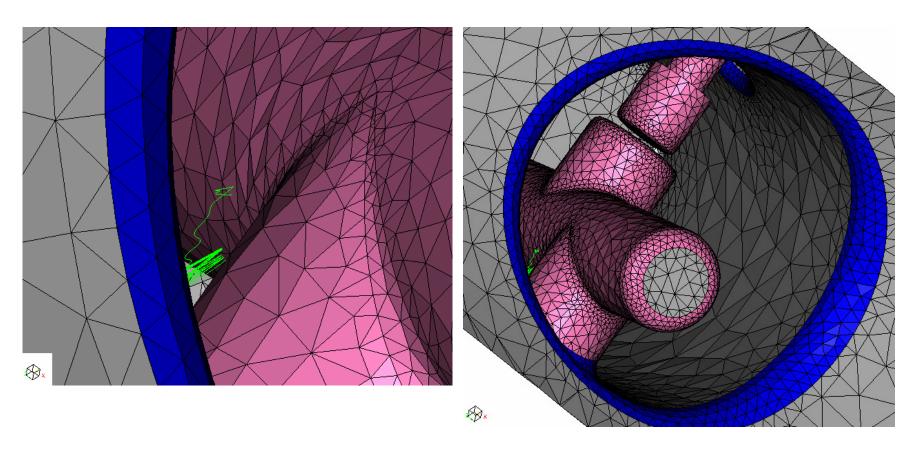


MP is founded at the field level 26 MV/m. The field is normalized for maximal electric field (Ex) on the axis



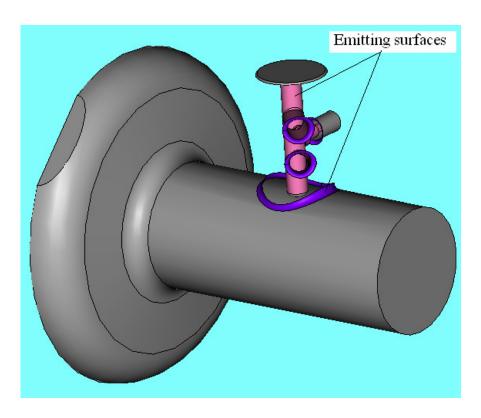


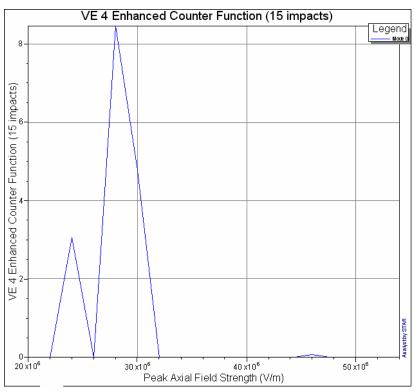
MP Phenomena in HOM Coupler



• MP at the field level 26 MV/m

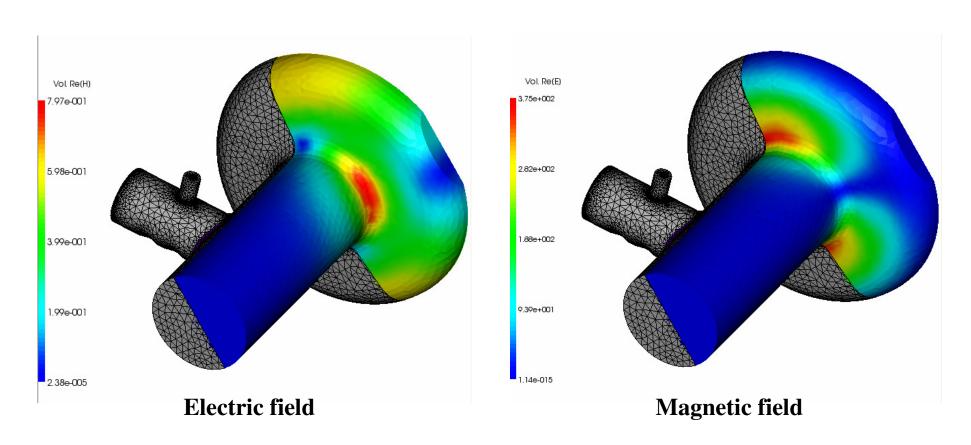
MP Study in 2-post HOM Coupler





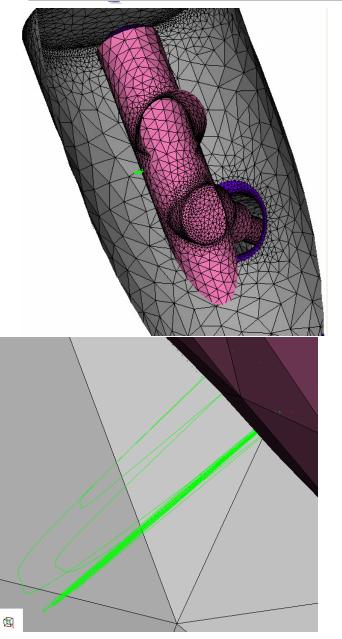
ECF shows the maximal MP activity at the field level about 28 MV/m.

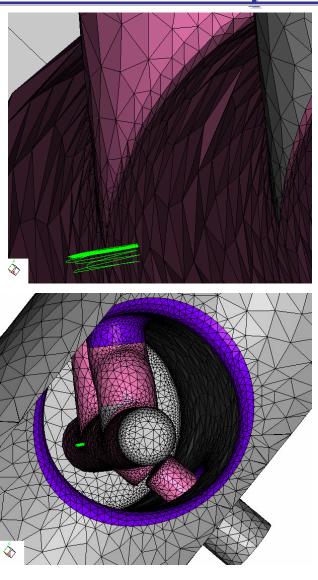
EM fields in 2-post HOM Coupler



Tetrahedral mesh 38,422 nodes; 194,000 elements; 235,000 DOF.

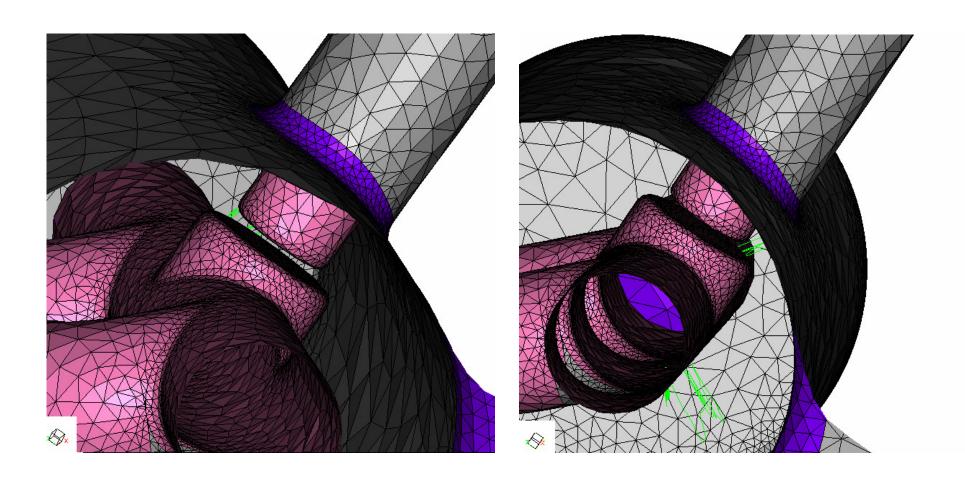
MP phenomena in 2-post HOM Coupler





MP trajectories for E = 28 MV/m

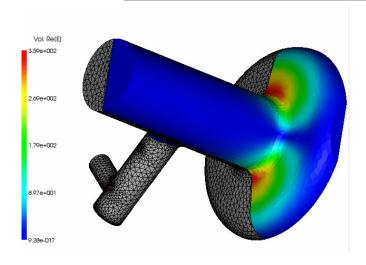
MP phenomena in 2-post HOM Coupler



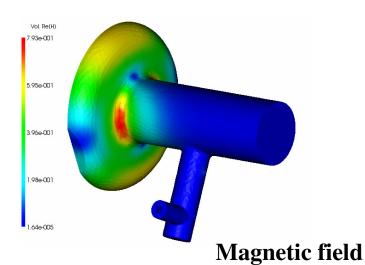
MP trajectories for E = 24 MV/m

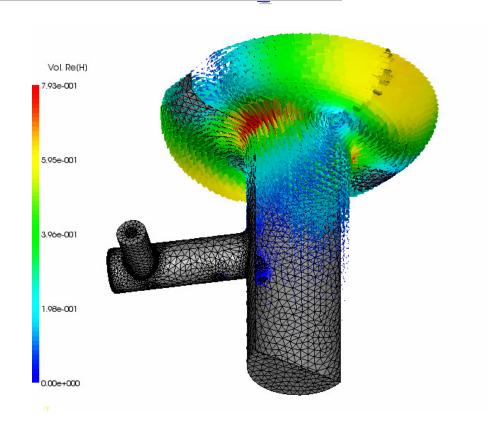
MP trajectories for E = 30 MV/m

EM fields in LOM Coupler



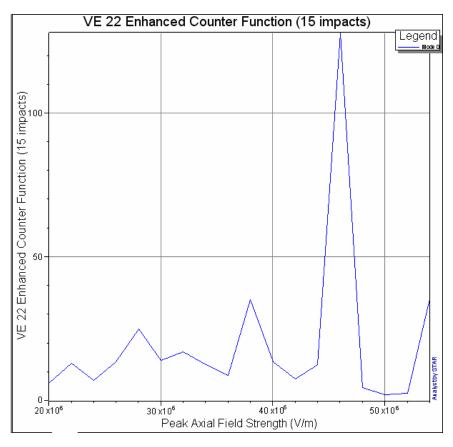
Electric field

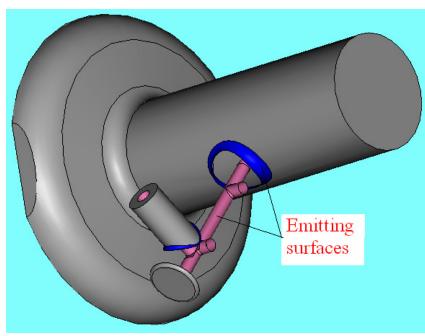




Tetrahedral mesh ~38,000 nodes.

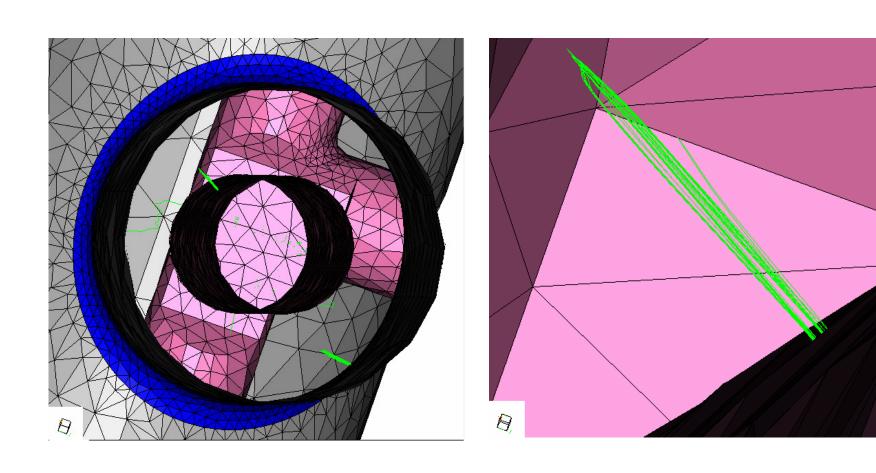
MP phenomena in LOM Coupler



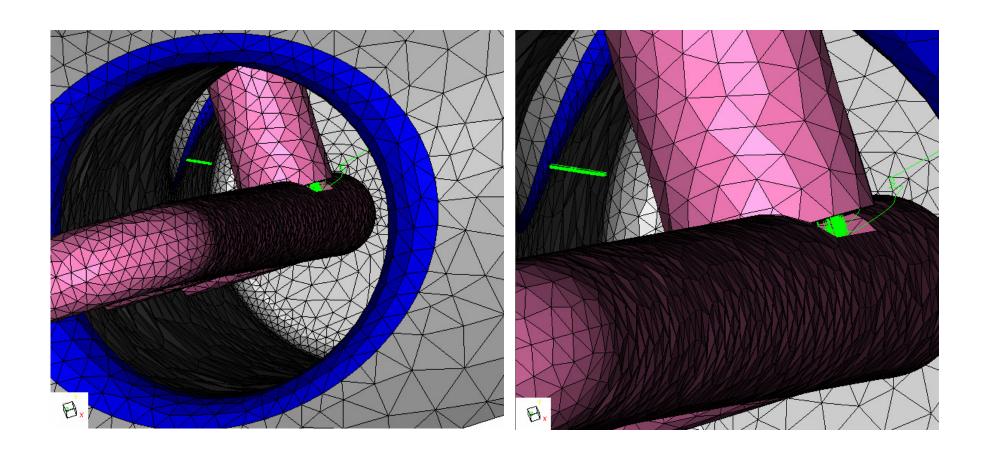


Maximal value for ECF corresponds to the field level about 36 MV/m

MP in LOM Coupler at 46 MV/m



MP in LOM Coupler at 46 MV/m



Acknowledgements

Special thanks to my colleagues:

- Ivan Gonin for the help in familiarization of the Analyst numerical simulation tool;
- Timergali Khabibulin for the geometry design for HOM & LOM couplers.

Summary:

- Analyst is a powerful tool for MP phenomena simulation for complex realistic rf devices in 3D;
- MP effects were founded and studied in LOM and HOM couplers for the Crab cavity;
- Our experience in using the Analyst tool allows us to formulate the requirements to improve the efficiency and post-processing features of the tool.